

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	63168	(wafer or substrate or semiconductor) near3 (rotate or rotated or rotating or rotation or revolve or revolved or revolving or spin or spinned or spinning)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2004/12/01 15:48
L2	1591700	(liquid or solution or fluid or electrolyte or water) near3 (flow\$5 or direct\$5 or suppl\$5 or pump\$5 or inlet or pass\$5)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2004/12/01 15:52
L3	13741	I1 and I2	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2004/12/01 15:52
L4	2848	I3 and (electroplat\$8 or electroly\$8 or electrodeposit\$8 or electrochem\$8)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2004/12/01 15:53
L5	2222	I4 and semiconductor	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2004/12/01 15:53
L6	133	I5 and (cathode near3 (ring or annular or circular or clamp or periph\$5))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2004/12/01 15:57
L7	127	I6 and anode	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2004/12/01 15:57